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On behalf of Nikhef and Physikalisches Institut Universität Bonn



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GridPix technology

- Pixel chip with integrated Micromegas
- => InGrid
- Grid set at negative voltage (300 600 V)
 to provide gas amplification
- Very small pixel size (55 μm)
- => mostly detecting individual electrons

GridPix chip





GridPix: detecting individual electrons

- Uses the complete information of the ionization profile
- The best resolution that can be obtained with a gaseous detector
 - dE/dx by single electron counting
- Fine granularity enables rejecting background tracks and deltas in offline analysis



Pixel chip: TimePix3

- **256 x 256 pixels**
- **55** x 55 μm pitch
- => 14.1 x 14.1 mm sensitive area
- **TDC with 610 MHz clock (1.64 ns)**
- Used in the data driven mode
 - Each hit consists of the **pixel address** and time stamp of arrival time (ToA)
 - Time over threshold (ToT) is added to register the signal amplitude
 - => compensation for time walk
 - **Trigger** (for t₀) added to the data stream as an additional time stamp
- High power consumption
 - \sim 1 A @ 2 V (2W), depending on hit rate
 - sood cooling is important





TimePix3 equipped with InGrid

- Wafer post-processing at IZM Berlin
- Aluminium grid (1 µm thick)
- $35 \,\mu\text{m}$ wide holes, $55 \,\mu\text{m}$ pitch
- Supported by SU8 pillars 50 µm high
- Grid surrounded by SU8 dyke (150 µm wide solid strip) for mechanical and HV stability





Mag = 250 X Signal A = SE2 EHT = 10.00 kV 20 µm*

Stage at T = 50.0 Fraunhofer IZM Chamber = 6.64e-004 Pa

WD = 14.3 mm

Maximizing active area

- Using TimePix3 chip
- Wirebond board squeezed to smallest width possible => 3 mm
- Inactive zone (wirebond pads + electronics) => 2 mm
- => we need a 5 mm wide inactive zone per chip for connection + electronics
- (only applies when the connecting
 PCB is shared with an opposite chip) 3 mm



Getting the optimal detector size

■ 1 x 2 chips

Not sufficient space (14 mm) for a LV stabilisation, chip control lines and a data RO

2 x 2 chips (QUAD)■ All fits

≥ 3 x 2 chips
 Less flexible, lower yield, more handling risk



Covering large detection areas: QUAD

Four-TimePix3 chips

All services (signal IO, LV power) are located **under** the detection surface

The area for connections was squeezed to the minimum

 Detection surface can be extended by adding other QUADs at all 4 sides

=> no limit on detection area



Assembled QUAD

QUAD has a sensitive area of 68.9%

QUADs being produced in series

(14 QUADs)



Contact us if you are interested



COld CArrier



QUAD's tooling

■ Based on small production quatities (up to ~ 50)

Chip alignment jig



Gluing tool





Pickup tool for chip with InGrid

- Semi automatic under LabVIEW
- Referring the precise edges of the COCA to the bonding pads

Chip aligment

Aimed accuracy 20 μm in X,Y and Z



- Last testbeam: small deformations QUAD edge deformations due to
 - Dead zone between chips
 - Grounded region between chips
- May be corrected by fitted correction function or adding proper guard electrode





QUAD as a building block

Unlimited surface may be covered

Building blocks of **39.6 x 28.38 mm**

 Plug in QUADs into a cooled gastight mounting plate

Push them from two sides to a mechanical reference



Testbox for 2 x 4 QUADs



- Being assembled
- Presently liquid cooling
 - Glycol

Guard structure around the QUADs Guard



Mounting plate for 8 QUADs being assembled



Thermal grease (outside gas volume)^{Fred Hartjes}

Testbox in assembly

Windows of optical glass for UV laser measurements



Conclusions

- Since 2017 three TimePix3 wafers were successfully equipped with an InGrid
 - Last two (low yield) wafers carried 88 electrically usable chips
 - Only a few were rejected because of grid problems
- The QUAD we present as a building block to populate an ILCTPC module
- A beam test showed the need for a narrow guard electrode structure covering the gap between the chips
- Presently the QUAD can be produced in limited quantities
 - One QUAD per two days can be achieved
 - A production of 14 QUAD modules is close to finish
- A testbox carrying 2 x 4 QUADs is being assembled
 - UV laser tests: focused and parallel beam (ionization in the gas)
 - Testbeam (Bonn)





Thank you for your attention



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